Observing the spin Coulomb drag in spin-valve devices

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A bstract

The Coulomb interaction between electrons of opposite spin orientations in a metalor in a doped sem iconductor results in a negative o -diagonal component of the electrical resistivity matrix { the so-called \spin-drag resistivity". It is generally quite dicult to separate the spin-drag contribution from more conventionalmechanisms of resistivity. In this paper I discuss two methods to accomplish this separation in a spin-valve device.

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It is theoretically well established [1]-[5] that the Coulomb interaction between electrons in a metalor in a doped sem iconductor has a deepere ect on spin-polarized currents than on ordinary spin-unpolarized ones. The main reason for this is that the dierence between the m om enta of the up-spin and down-spin electrons is not conserved in a Coulomb scattering event: the transfer of m om entum between electrons of opposite spin orientations therefore provides an intrinsic mechanism for the decay of a spin current, even in the absence of electron-in purity scattering. This e ect has been called \spin Coulomb drag" 1], or just spin drag for brevity. M athem atically, the spin-drage ect is best described in terms of the so-called spin transresistivity "#, which is de ned as follows: Let j and j# be the electrical currents associated with up- and down-spin electrons (we consider here for simplicity only currents in the x-direction and neglect spin-orbit e ects), and let $E_{\rm r}$, $E_{\rm \#}$ be the electrochemical elds acting on the up-and down-spins respectively (The electro-chemical eld E is de ned as the gradient of the electro-chem ical potential divided by e. The electrochemical potential itself is the sum of the true electric potential, which determines the position of the bottom of the conduction band, and the chem ical potential, which determ ines the level of occupation of the band.) Then, for small departures from equilibrium one has

$$E = X$$
 $\circ j \circ ;$ (1)

where the resistivity matrix \circ has the form $[\beta]$

In the above equation is the spin-drag one cient, i.e., the intrinsic relaxation rate of the spin momentum p_n p_n , $\frac{1}{n}$ is the ordinary momentum relaxation rate due to electron impurity interactions, m and e are the band mass and the absolute value of the electron charge, and n is the total electronic density. Eq. (2) is valid under the assumption that the spin-ip scattering rate is negligible in comparison to { a condition that should be well satistic edexcept at very low temperatures 4]. We have also assumed, for simplicity, that the system is paramagnetic, i.e., $n_n = n_{\#} = \frac{n}{2}$, so that $n_n = n_{\#}$. Looking at Eq. (2) we notice an important fact: $n_{\#}$ is negative, because it takes a negative electro-chemical eld to prevent an up-spin current from owing when a down-spin current is present. On the other hand, the positivity of dissipation requires both eigenvalues of to be positive { a condition that is obviously satistic edex of the provided is positive.

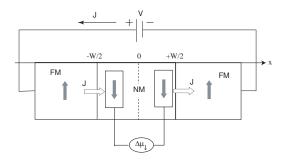


FIG. 1: Spin-valve device for the measurement of the spin drage ect. A predom inantly upspin current is injected in a non-magnetic (NM) sem iconductor via ferromagnetic (FM) electrodes between which a potential dierence V is applied. The voltage probes are polarized oppositely to the injectors and therefore measure the down-spin electro-chemical potential.

Thus, a very important question concerning this proposal is: how large should the polarization of the electrodes be so that one may observe a negative down-spin electro-chemical potential dierence (as opposed to the trivially positive electric potential dierence)?

This paper is largely devoted to providing a sharp answer to this question. It will be shown (see Eqs. (9) and (10) below) that as p increases from 0 to 100% there is a critical value of p, given by $p_c = \frac{1}{1+}$, at which the electro-chem ical potential drop for down-spins

sw itches from positive to negative. M easuring p_c am ounts therefore to a m easurem ent of . The experim ent could be carried out in a three-layer spin-valve structure [8, 9, 10, 11, 13], such as the one shown in Fig. 1. The two electrodes/spin injectors could be made out of a large-g-factor II-VI sem iconductor, e.g. $Be_xMn_yZn_{1-x-y}Se$, where g=100 [2], which can be completely polarized by the application of a modest magnetic eld. These electrodes are used to inject a spin-polarized current into a nonmagnetic (NM) lightly doped sem iconductor (e.g., GaAs) and the total resistance across the electrodes is measured. The main physical assumptions underlying the proposed measurement are as follows:

- 1. The spin drag e ect is important only in the nonmagnetic semiconductor (GaAs), where the density of carriers is low. This is because it is theoretically well established that the spin drag increases in magnitude as the density of the electrons decreases [1].
- 2. The magnetic eld, which is needed to spin-polarize the electrodes, has a negligible e ect on the electronic states in the non-magnetic semiconductor, in which the g-factor is small.
- 3. The spin-resolved conductivities of the electrodes f_{mm} and f_{mm} scale in proportion to the corresponding electron densities, i.e., $f_{mm} = \frac{1+p}{2}$ f and $f_{mm} = \frac{1-p}{2}$ f, where f is the total conductivity of the hom ogeneous ferrom agnet. (O f course f itself m ay slightly depend on p: this question will be discussed below.)

The analysis is based on the equation for the electro-chem ical potentials derived in Ref. [6]. In the one-dimensional geometry of Fig.1 this takes the form

$$\frac{d^2(x)}{dx^2} = X \qquad M \qquad 0 \qquad 0 ;$$
 (3)

where the 2 2 m atrix M $_{\circ}$ is, for our purposes, completely specied by its right eigenvectors, namely 0 1

(the charge m ode) with eigenvalue 0, and

(the spin mode) with eigenvalue $\frac{1}{L^2}$, where L is the spin di usion length. The solution of Eq. (3) is straightforward. To make the best use of sym metry we assume that the sem iconductor layer extends from x = W = 2 to x = W = 2. The electro-chemical potentials are then odd functions of x = (x) = (x), and we can focus only on the region x < 0. In this region we write

where J is the charge current, f and s are the conductivities of the electrodes and of the sem iconductor, and L^f and L^s the spin di usion lengths in the electrodes and in the sem iconductor, respectively. Notice that the continuity of the charge current, J, is already built in Eq. (6). The three constants C_0 , C_1 , and C_2 are determined from the continuity of the two electro-chemical potentials and of the spin current $j_r(x) = j_r(x)$ at x = W = 2. Their explicit forms are easily found to be

$$C_{0} = \frac{f}{s} + \frac{2p^{2}}{D} \sinh \frac{W}{2L^{s}};$$

$$C_{1} = \frac{p(1 \quad \vec{p})}{2D} \sinh \frac{W}{2L^{s}};$$

$$C_{2} = \frac{p^{s}}{2^{f}D};$$
(7)

with

$$D = \frac{W (1 \ p^2)}{T_{.}^f} \sinh \frac{W}{2T_{.}^s} + \frac{W^s}{T_{.}^s} \frac{1}{1 + \cos h} \cos h \frac{W}{2T_{.}^s}$$
 (8)

As mentioned above, the solution for x > 0 is obtained by means of the symmetry relation (x) = (x).

The behavior of the solution (expressed in units of eJW = s) is shown in Fig. 2. Basically, we observe an accumulation of down-spin electrons and a corresponding depletion of upspin electrons (i.e., $_{\#} > _{\#}$) at the left interface, where up-spin electrons are injected. The opposite happens at the left interface, where up-spin electrons are extracted. These spin accumulations electrons ectively create a discussion barrier, which increases the resistance and reduces the electron of spin-current injection. Under the assumption L^s W the electrochemical elds, defined as the slopes of the electrochemical potentials divided by e, are nearly

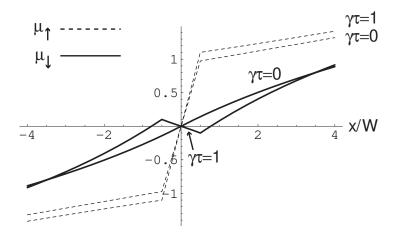


FIG. 2: The behavior of the electrochem ical potentials " (dashed lines) and # (solid lines) calculated from Eq. (6) for = 0 and = 1 and expressed in units of $\frac{eJW}{s}$ in the parallel-electrodes conguration. The sem iconductor is in the region $\frac{1}{2} = \frac{x}{W} = \frac{1}{2}$. The other parameters are p = 90%, $\frac{f}{s} = 10$, $\frac{L^s}{W} = 2$, and $\frac{L^f}{W} = 4$. Notice the negative slope of # (x) at x = 0 when = 1: such a negative slope is an unm istakable signature of the spin drag.

exactly uniform in the nonmagnetic region and their values are given by

$$E_{\#}(0) = \frac{J}{s} + \frac{JW p}{L^{s} f D}$$

$$E_{\#}(0) = \frac{J}{s} = \frac{JW p}{L^{s} f D} :$$
(9)

Notice that $E_{\#}$ is always smaller than $E_{\#}$ and would tend to zero for p! 100% in the absence of the spin drag e ect. This is because as the polarization of the electrodes increases, the down-spin component of the current must decrease: in the absence of spin drag this would imply that a gradient in them ical potential of down-spin electrons must be present to balance the electric eld, resulting in $E_{\#}$ 0. The spin drag upsets this balance. It is now necessary to have a nite, negative $E_{\#}$ in order to balance the momentum transfer from up—to down-spin electrons. The change in sign in $E_{\#}$ is an unmistakable signature of the spin C oulomb drag and occurs when the spin polarization of the electrodes exceeds the critical value

$$p_{c} = \frac{q \frac{1}{1 + 4^{2} \sinh^{2} \frac{W}{2L^{s}} + 2 \sinh \frac{W}{L^{s}} \frac{1}{1 +}}{2 \sinh \frac{W}{2L^{s}}}}{2 \sinh \frac{W}{2L^{s}}}$$

$$(10)$$

where $\frac{L^s}{L^f}$ (notice that $p_c > 1$ for = 0, that is, in the absence of spin drag. For = 1 with the parameters of Fig. 2 we have $p_c = 0.85$). Thus by measuring the value of p at which $E_{\#}$ changes sign one can determ ine .

The main drawback of such an experimental design (which is conceptually analogous to the design of the Coulomb drag measurement in bilayer systems [7]) is the need to establish separate electrical contacts for the up-and down-spin electrons. This could be accomplished by the introduction of ferrom agnetic voltage probes, polarized oppositely to the current leads. Unfortunately, such \probes" are technically di cult to implant and complicate the analysis of the experiment, for they disturb the equilibrium distribution of the spin in the sem iconductor. For this reason I now describe what should be a simpler method to determ ine the quantity 1+ . The idea of the m easurem ent is simply to compare the total resistance R of the circuit at p = 0 (i.e., for unpolarized electrodes) and p = 1 (i.e., 100% spinpolarized electrodes). No spin-polarized voltage probes are required. We assume that the hom ogeneous resistance of the electrodes and the external wires (denoted by R_c for brevity) is small compared to the resistance of the non-magnetic semiconductor. The polarization dependence of R_c presum ably amounts to an even smaller correction. At p = 0 the total resistance is thus essentially equal to the ordinary resistance of the sem iconductor: the spindrag e ect is invisible here. At p = 1, on the other hand, the resistance depends very much on whether there is spin drag or not. If the spin drag were absent, then the resistance would be twice the ordinary resistance of the semiconductor, because only one of the two spin channels is open to conduction. In the presence of spin drag the ow of the up-spin current is hindered by collisions with down-spin electrons, which are stationary on the average: as a result, the resistance of the conductor becomes more than twice the ordinary resistance { in fact we will show that it is 2+ times the ordinary resistance. Thus, by taking the dierence R (p = 1) R (p = 0) and dividing it by R (p = 0) we arrive at an experimental determination of . It should be noted that in taking the dierence R (p = 1) R (p = 0) the resistance R_c of the wires and the electrodes largely cancels out, except for its polarization-dependent component, which we feel justi ed in neglecting. Furtherm ore, this determ ination does not depend on the value of the spin di usion length in the sem iconductor, Ls, provided the latter is much larger than the length of the sem iconductor itself, W { a condition that should not be too di cult to satisfy in practice. Likewise, the value of the spin-di usion length in the electrodes, Lf, is essentially irrelevant as long as the potential drop is measured between

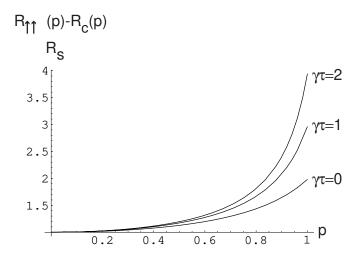


FIG. 3: Behavior of the parallel-electrodes m agneto-resistance $R_{parallel}(p)$ $R_c(p)$ (in units of the ordinary resistance of the sem iconductor, R_s) as a function of p for = 0, 1, and 2. Notice the sharp enhancement caused by the spin-drag resistivity for values of p close to 100%. As explained in the text, this can be used to determ ine .

points that are much farther than a distance Lf from the FM-NM interfaces.

Far from the FM-NM interfaces (m ore precisely, at a distance much larger than L^f) the electro-chem ical potentials of the two spin orientations tend to common values = $\frac{eJW (C_0-1)}{2^f} + \frac{eJx}{f}$ for x! 1 and $_+ = + \frac{eJW (C_0-1)}{2^f} + \frac{eJx}{f}$ for x! +1. The di erence between these two asymptotic behaviors is e times the voltage drop due to the presence of the sem iconductor layer. Hence, the resistance of our device (per unit cross-sectional area) is given by

$$R_{parallel}(p) = R_{c}(p) + R^{s} + \frac{2W p^{2}}{D f} \sinh \frac{W}{2L^{s}}$$
; (11)

where R_c (p) is the combined resistance of the electrodes and the external wires, and $R^s = \frac{W}{s}$ is the ordinary resistance of the sem iconductor. The last term on the right hand side of this equation arises from the spin accumulations at the interfaces between the electrodes and the sem iconductor. Fig. 3 shows the behavior of the key quantity $R_{parallel}$ (p) R_c (p) as a function of p. It increases from R_s at p=0 to R^s (2+) at p=1. Interestingly most of the change occurs in the region of p close to 1. This can be exploited to reduce the undesired electrodes in the p-dependence of R_c . Namely, rather than considering the change in resistance from p=0 to p=1, it may be sulcient to consider the change from say p=0.5 to p=1.0 with correspondingly less variation in R_c . Notice that heoretical calculations of

as a function of temperature and electronic density can be found in Refs. [1]-[4]. The temperature dependence of is particularly interesting as it exhibits a characteristic broad maximum at about the degeneracy temperature of the carriers in the sem iconductor.

For completeness, let us now see what happens in the antiparallel-electrodes conguration. In this case, the electro-chemical potentials obey the symmetry relation (x) = (x) and it is easy to see that the new solution is now obtained from the parallel case solution $\lim_{n \to \infty} \| \| \|_{L^{\infty}} \|$

where the constants C $_0^0$ C_2^0 are given by

$$C_{0}^{0} = \frac{f}{s} + \frac{2p^{2}}{D^{0}} \cosh \frac{W}{2L^{s}};$$

$$C_{1}^{0} = \frac{p(1 + p^{2})}{2D^{0}} \cosh \frac{W}{2L^{s}};$$

$$C_{2}^{0} = \frac{p^{s}}{2^{s}D^{0}};$$
(13)

and

$$D^{0} = \frac{W (1 p^{2})}{L^{f}} \cosh \frac{W}{2L^{s}} + \frac{W^{s}}{L^{s}} \frac{1}{1+} \sinh \frac{W}{2L^{s}} : \qquad (14)$$

The solution for x > 0 is obtained by m cans of the sym m ctry relation (x) = (x). A representative plot of $_{\pi}$ and $_{\#}$ is shown in Fig. 4.

We can calculate the resistance of the antiparallel-electrodes conguration in precisely the same way as in the parallel-electrodes case. The result is

$$R_{antiparallel} = R_c(p) + R^s + \frac{2W p^2}{D^{of}} \sinh \frac{W}{2L^s} ; \qquad (15)$$

and the quantity $R_{antiparallel}(p)$ $R_{c}(p)$ is plotted vs p in Fig. 4. The resistance of this conguration is of course much larger than that of the parallel conguration (this is the well-known GMR e ect) and it is easy to see that in the limit p! 1 it tends to to $R^{s}(1 + \frac{2L^{s}}{w})^{2}$. Notice that the Coulomb enhancement in this conguration is very sharply

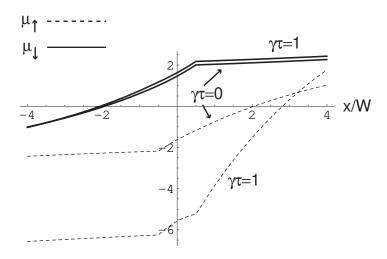


FIG. 4: The behavior of the electrochem ical potentials " (dashed lines) and " (solid lines) calculated from Eq. (12) for = 0 and = 1 and expressed in units of $\frac{eJW}{s}$ in the antiparallel-electrodes con guration. The parameters are the same as in the caption of Fig. 2, namely p = 90%, $\frac{f}{s} = 10$, $\frac{L^s}{W} = 2$, and $\frac{L^f}{W} = 4$.

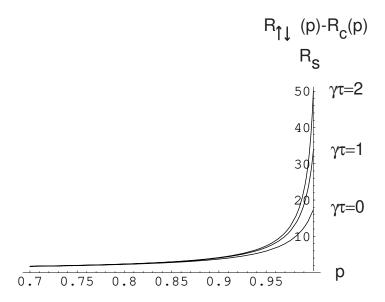


FIG. 5: Behavior of the antiparallel-electrodes m agneto-resistance $R_{parallel}(p) = R_c(p)$ (in units of the ordinary resistance of the sem iconductor, R_s) as a function of p for = 0, 1, and 2. The enhancement caused by the spin-drag resistivity for values of p close to 100% is now amplied by a factor $\frac{2L^s}{W}$ (= 16 in the present case). As explained in the text, this can be used to mesaure $\frac{L^s}{W}$ once is known.

con ned to the region of p $\,$ 1. The results of the above calculation can be used to determ ine $\frac{L^s}{W}$, once has been determ ined from the measurement of the resistance in the parallel-electrodes con guration.

In sum mary I have theoretically analyzed in this paper two methods to measure the spin drag coe cient of a non-magnetic semiconductor sandwiched between highly spin-polarized ferrom agnetic electrodes. The rst method builds upon the gedanken experiment proposed in Ref. [1] showing that an unambiguous qualitative signature of the spin drag electrodes when the spin polarization of the ferrom agnetic electrodes exceed the critical value p_c $\frac{1}{1+}$. In the second, more quantitative method one simply measures the extra resistance introduced by the relative motion of the up-spin and down-spin electrons in the semiconductor region of a basic spin-valve device. It is hoped that these discussions will encourage further experimental work aimed at the observation of the spin Coulomb drag.

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